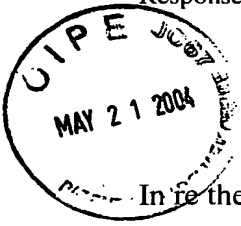


Application No. 10/033,644.
Non-Final Office Action mailed 2/18/04.
Response to Non-Final Office Action mailed 5/18/04.

2823
IFW



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

Katrina MIKHAYLICHENKO et al.

Application No. 10/033,644

Filed: December 27, 2001

For: METHOD FOR POST-ETCH AND STRIP
RESIDUE REMOVAL ON CORAL FILMS

)
) Group Art Unit: 2823
)
) Examiner: Nguyen, Khiem D
)
) Atty. Docket: LAM2P316
)
) Date: May 18, 2004
)

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail to: Commissioner for Patents, Alexandria, VA 22313-1450 on May 18, 2004.

Signed: _____

Feb Cabrasawan

AMENDMENT

Commissioner for Patents
Alexandria, VA 22313-1450

Sir:

This paper is in response to a Non-Final Office Action mailed on February 18, 2004.

Please enter the following:

Listing of Claims begin on page 2.

Remarks begin on page 7.